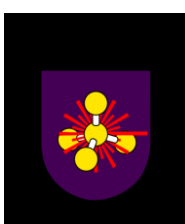


# Deep level system Gaussian approximation according the extrinsic photoconductivity in irradiated Si diodes.

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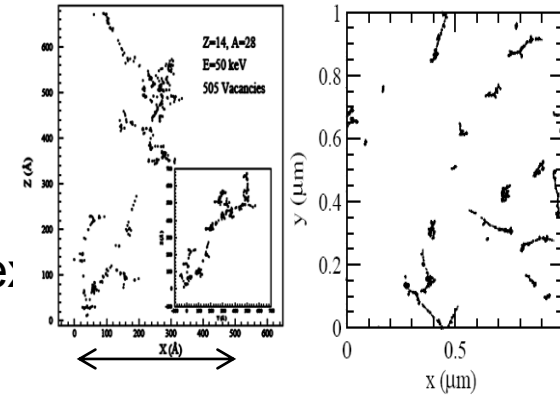
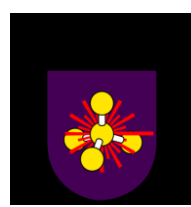


# Why photoconductivity?

- If the deep centers are important, the optical excitation excites **ALL** centers (except of those, that due to a strong electron-phonon interaction create the metastable state without a possible optical transition in the extrinsic range, e.g., EL2\* center in GaAs).
- Electrical methods feel the centers that are active
  - (e.g., if the center is surrounded by the repulsive barrier, it is almost **not seen** (except by carrier scattering, or its capture cross-section is very small) )
- Therefore, if a correct model of semiconductor is awaited, then optical absorption (**low sensitivity**), or photoconductivity (**high sensitivity**) methods are applicable.

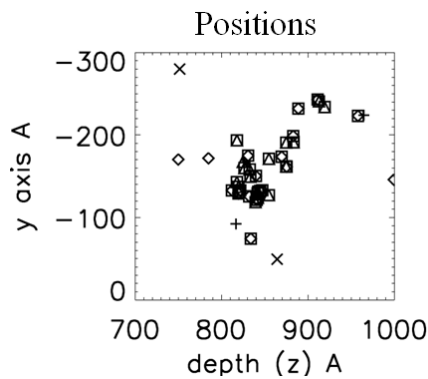
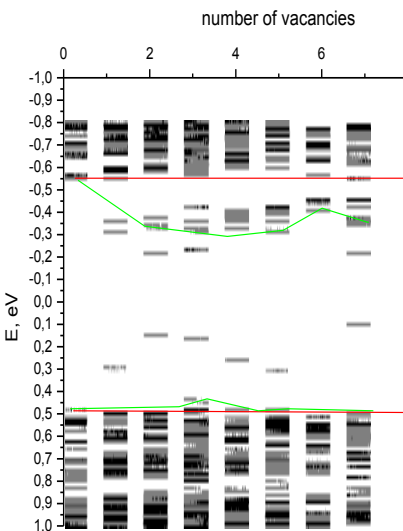
# The actual deep level energy spectrum models:

The kick off by neutron Si atom creates a track, consisting vacancies and Si disorder, some vacancies can be generated in a bulk (if the Si is irradiated by protons, then vacancies in the bulk concentration is bigger) (Huhtinen)

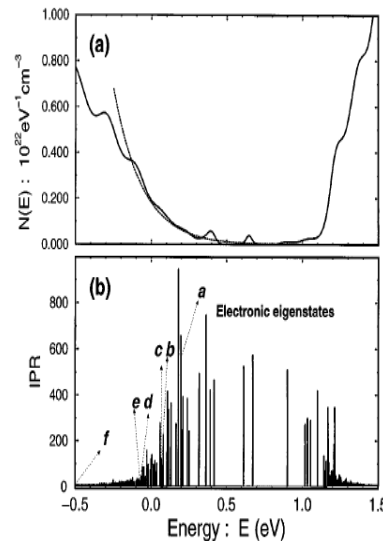


Three type of defects have to be created:

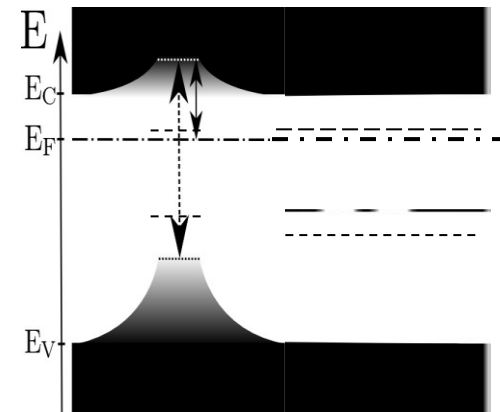
- 1) the vacancies, multi-vacancies, vacancy-interstitials complex;
- 2) Vacancy-impurity complexes,
- 3) Clusters, consisting different complexes inside



G.Davies, RD50



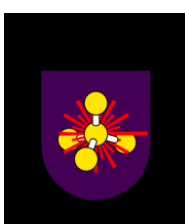
Initial distribution of Vacancies produced by 1 MeV neutron in Si, a – a result of kick of Si atom, and b – if a fluence was  $10^{14} \text{ cm}^{-2}$ , according M.Huhtinen. NIMA 491 (2002) 194–215



J.L. Hastings et al. Vacancy aggregates in silicon. Phys. Rev. B, 56, p. 10215 (1997).

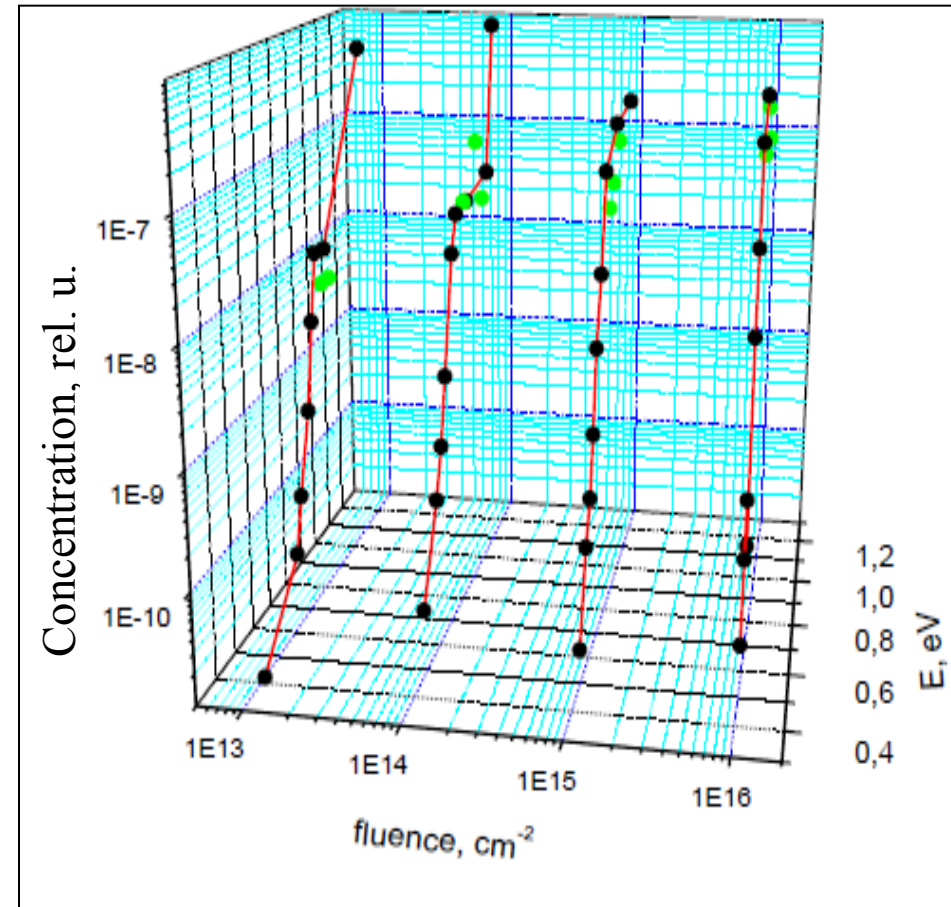
The valence tail is primarily due to structural disorder, the conduction tail is much more sensitive to temperature and originates in thermal disorder.

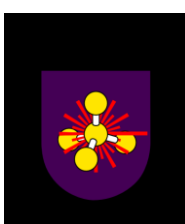
J. Dong, D. A. Drabold. Atomistic Structure of Band-Tail States in a-Si. Phys. Rev. Lett. 80., 1928 (1998).



# Earlier results (related to this talk)

- Investigation of deep centers in the irradiated Si
  - Our results presented in RD50 Workshops
- **This presentation, due to high number of centers, was found too complicated or not enough evident.**
- Therefore a possible distribution of deep level energies was analyzed and the approximation by Gaussian model is presented in this talk.



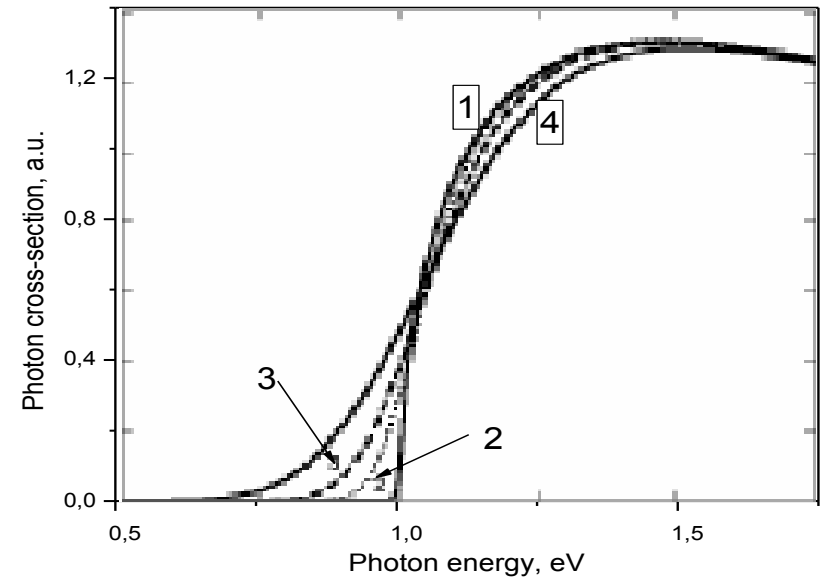


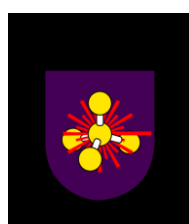
# Basics about the deep levels

- If the deep level property  $\delta$ -**potential** then Lukovsky model can be applied for the data analyze.

$$I \sim m \times \Delta E_M^{0,5} (h\nu - \Delta E_M)^{1,5} / (h\nu)^3$$

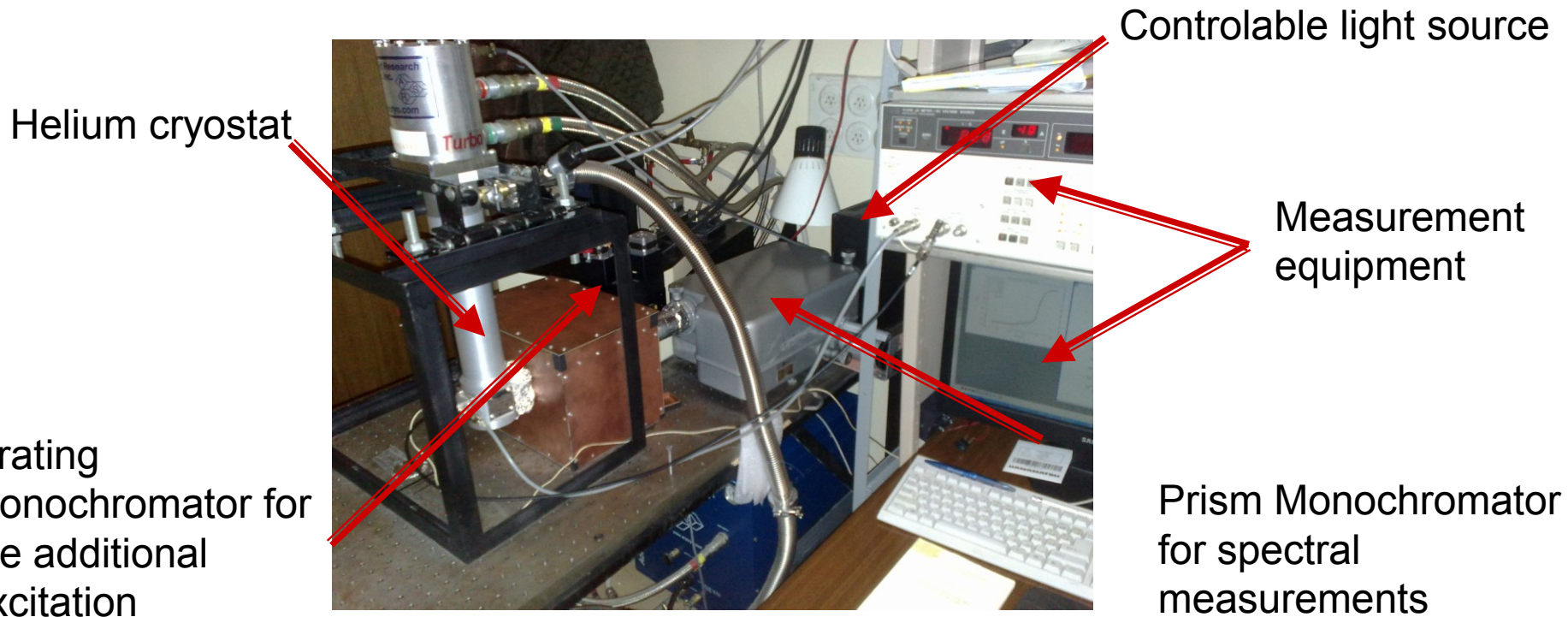
- This model (at low temperatures) does not valid:
  - for the hydrogen type defect
  - &
  - for the inter-deep level state transitions
- Low temperature requires the attention on the filling of the traps and to avoid the influence of electron-phonon coupling

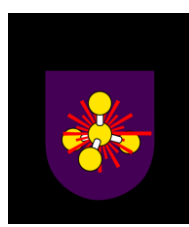




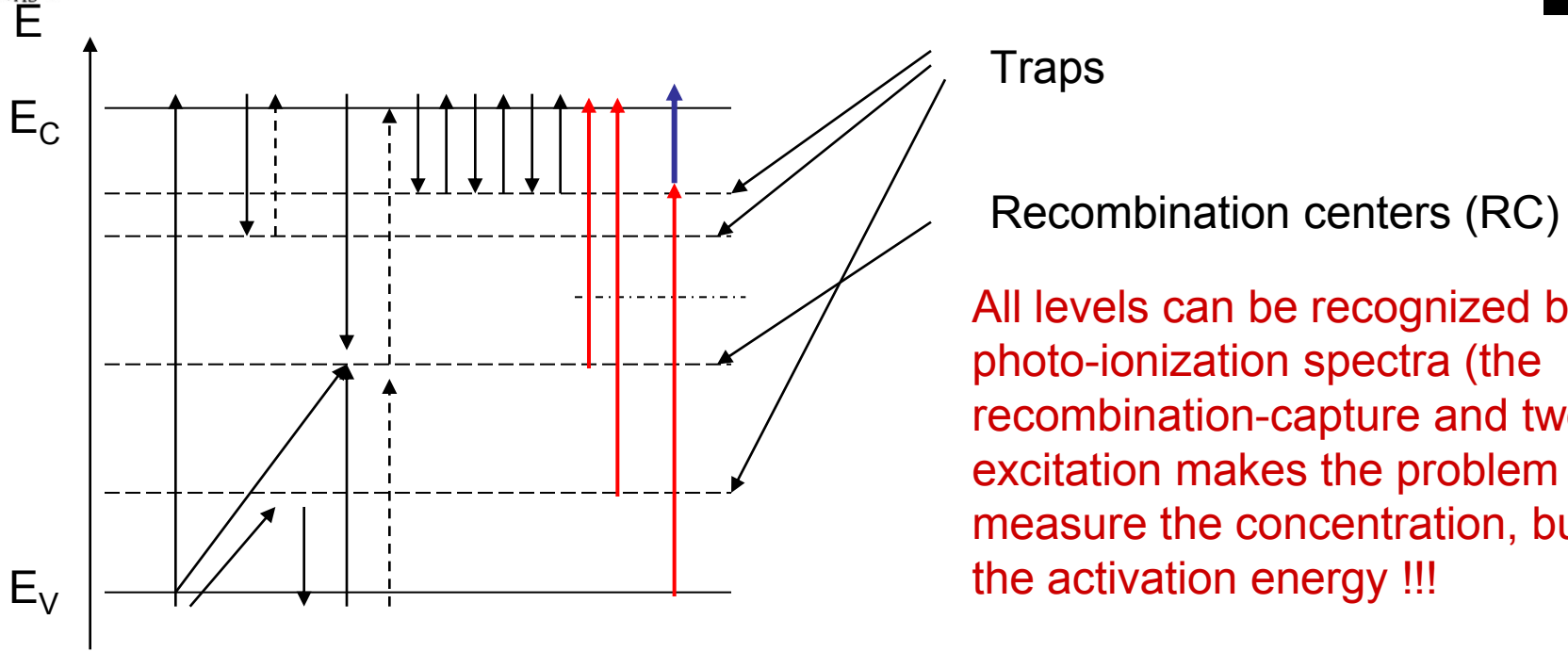
# In this series of analyze we modified the measurement equipment:

Now the equal number of light quantum was kept at each wavelength of the excitation. In earlier measurements the linear dependence of photoresponse on excitation was proposed (and checked for some cases, but not for all samples).





# Investigation of Traps and Recombination centers

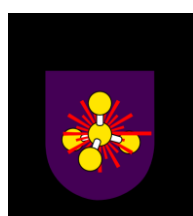


All levels can be recognized by photo-ionization spectra (the recombination-capture and two-step excitation makes the problem to measure the concentration, but not the activation energy !!!)

The traps recognition in homogeneous sample –most common - by the Thermally Stimulated Current methods

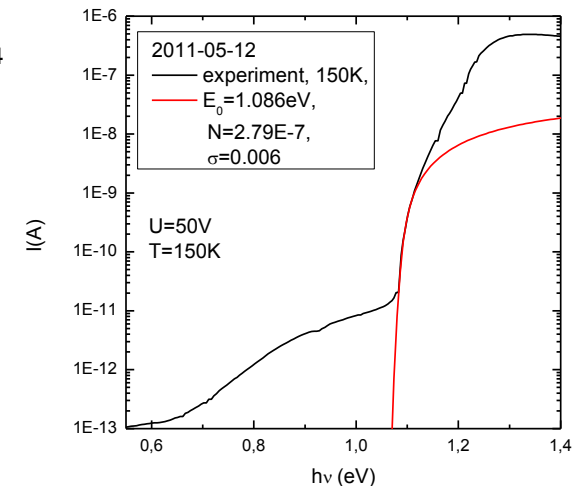
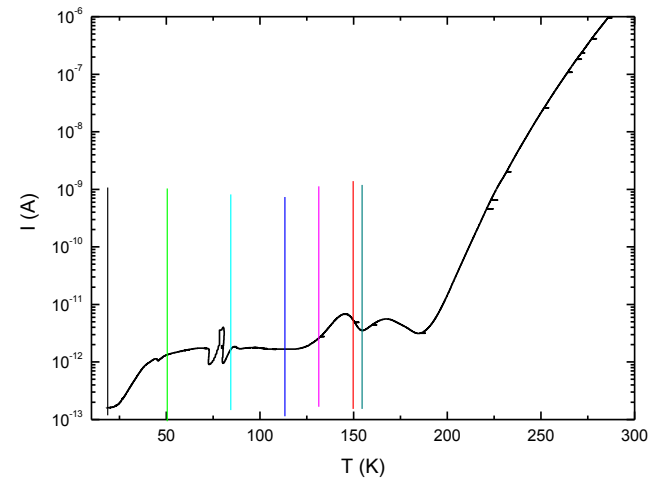
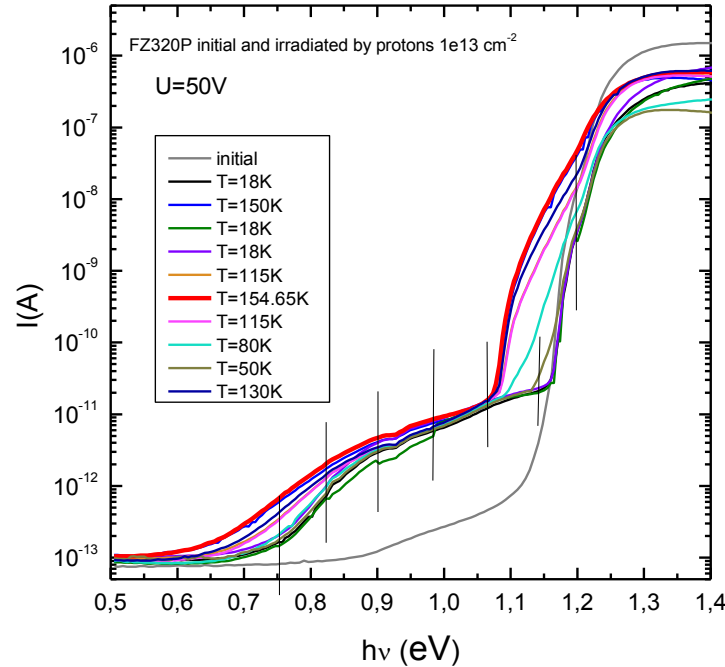
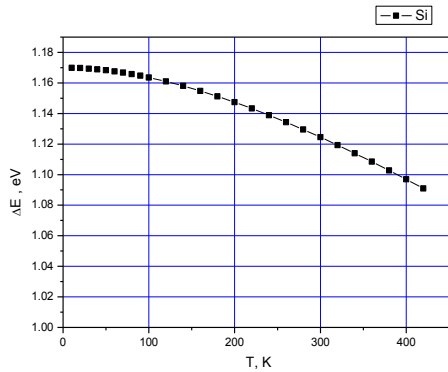
- illumination at low T,
- Wait until free carrier recombine (if some of them do not recombine and the current does not disappear, it is a signal that the free  $e$  and localized  $h$  are separated by a barrier),
- linear increase of T **OR**
- Multiple heating and cooling by  $\Delta T$





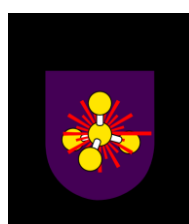
# Two step excitation of carriers

(the effect observed in the CMS CEC proton irradiated samples)



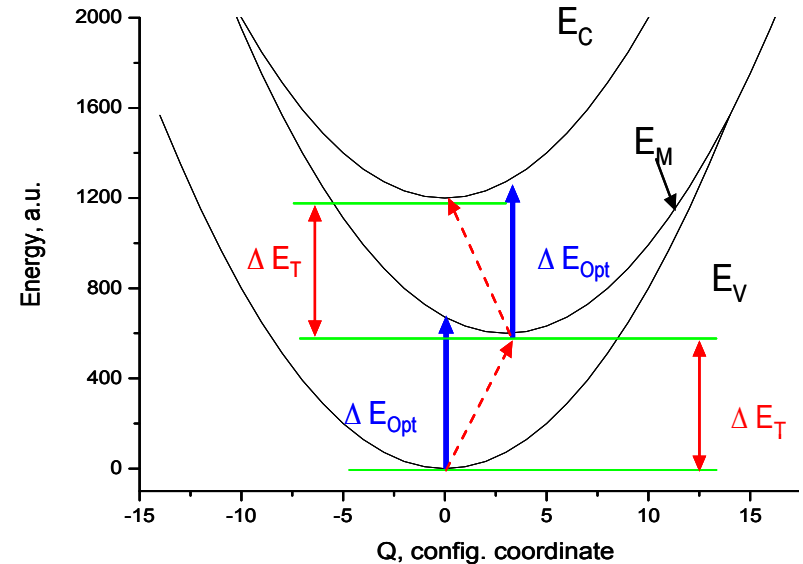
Measurement at higher T revealed the additional photoconductivity band due to the thermal excitation of electrons excited TO the deep center (1.086<sup>o</sup> eV) and then by thermal excitation TO the conductivity band. This trap  $\Delta E_T \sim 0,257 \text{ eV}$  (from TSC analysis)





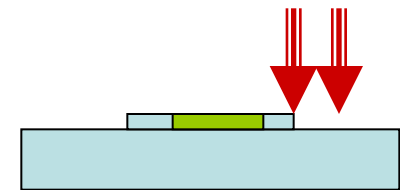
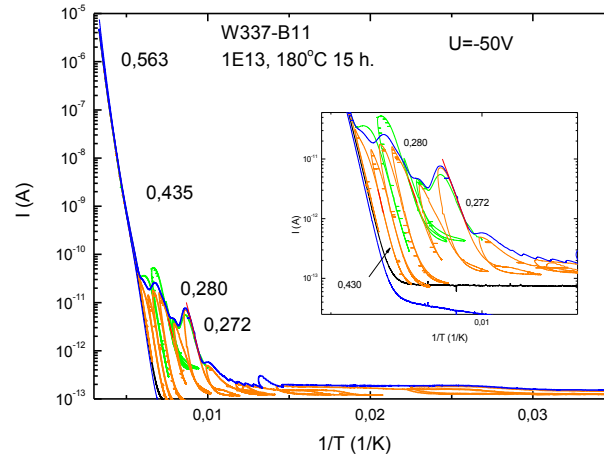
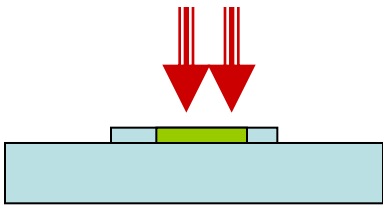
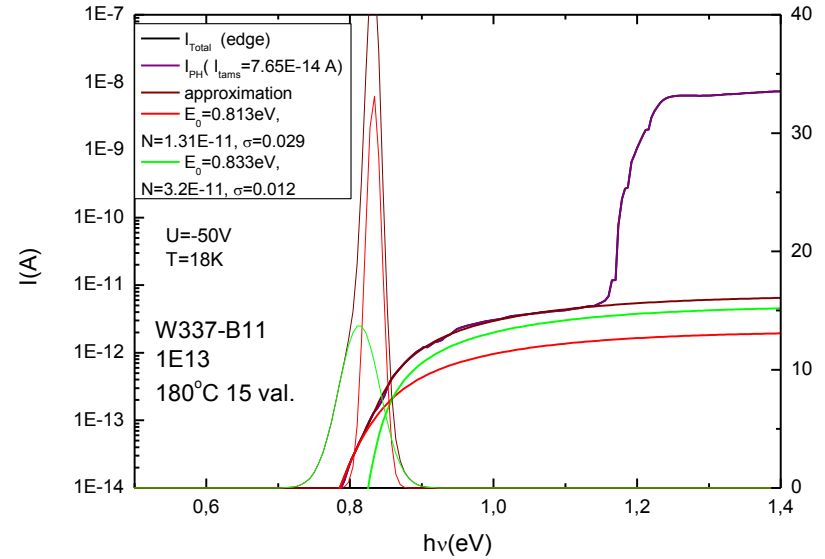
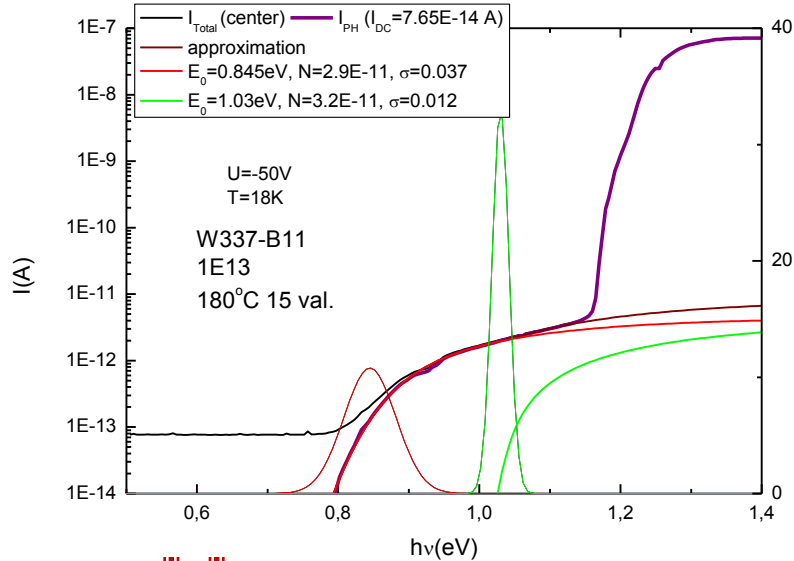
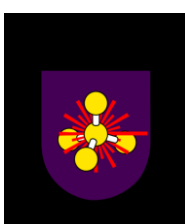
# If electron-phonon coupling is important:

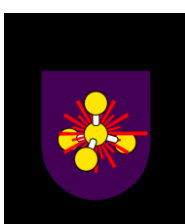
- At higher T measurement the electron-phonon coupling has to be included.
- If electron-phonon coupling is important, the configuration coordinate presentation has to be used.



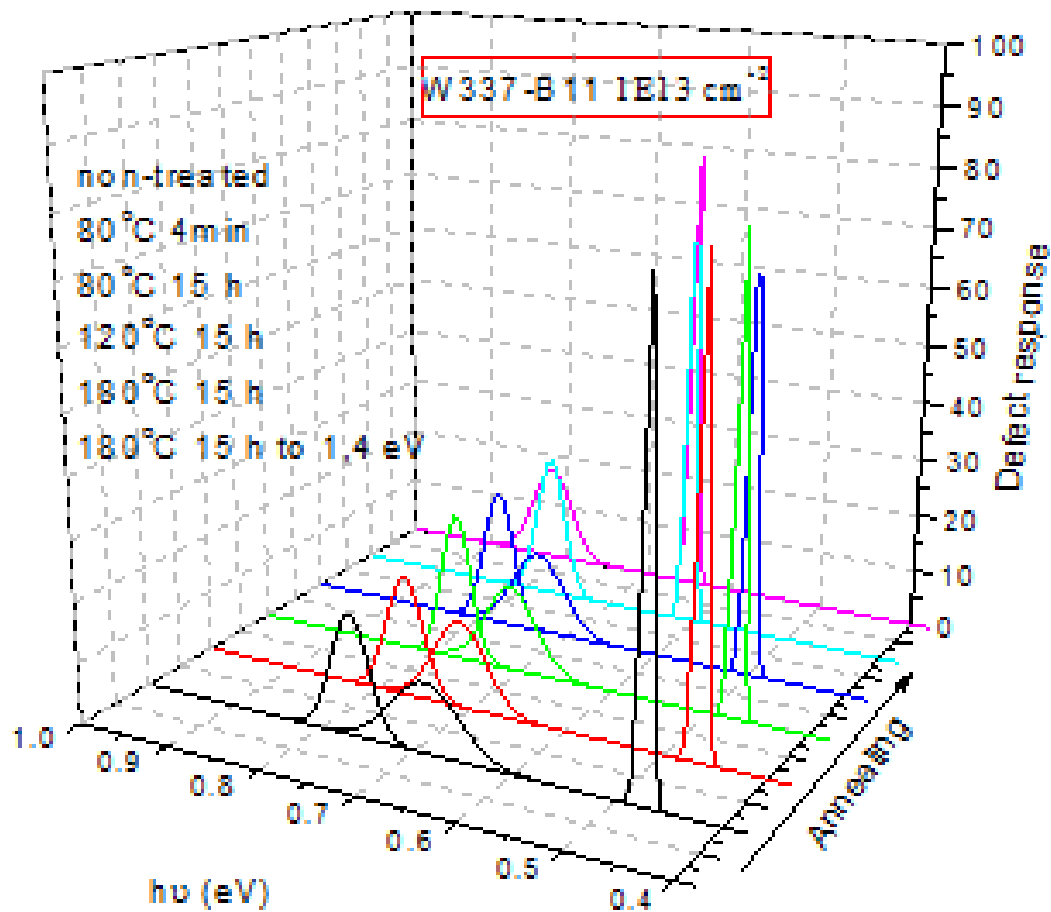
$$\Delta E^{OPT} - \Delta E^{TH} = \text{Frank-Condon shift, in Si} \sim 50\text{-}70 \text{ meV}$$

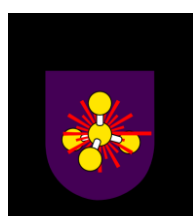
# Wodean samples $1e13 \text{ cm}^{-2}$



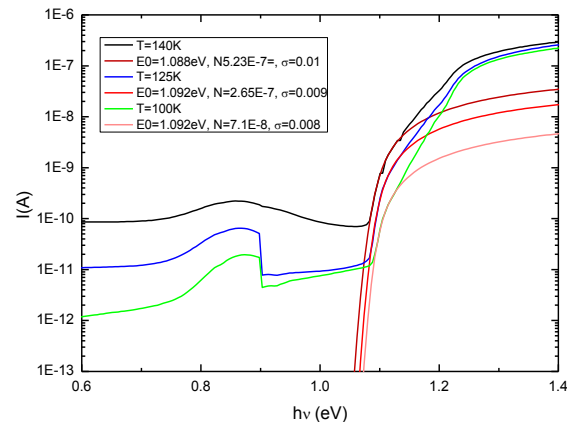
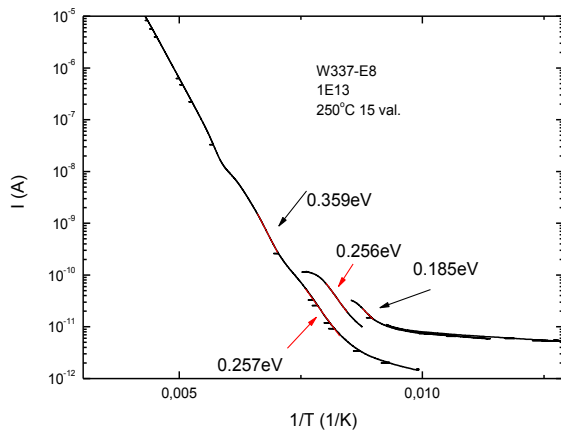
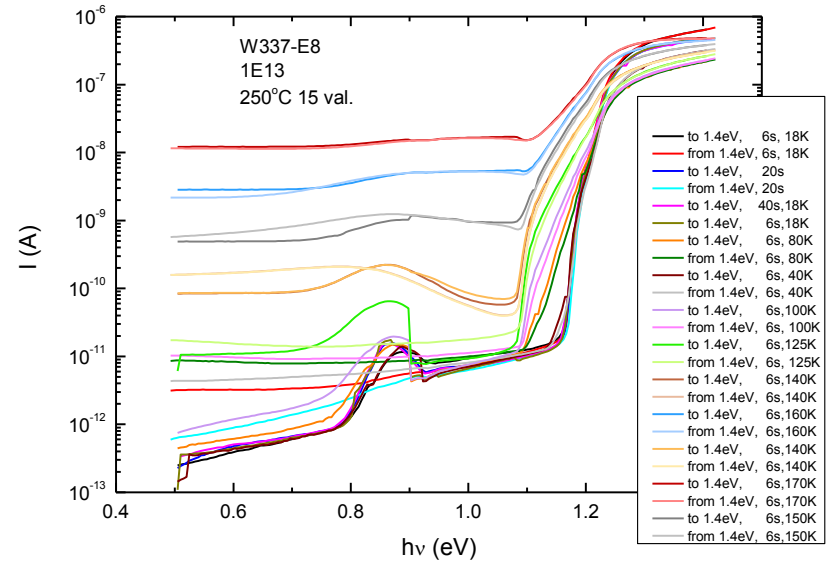
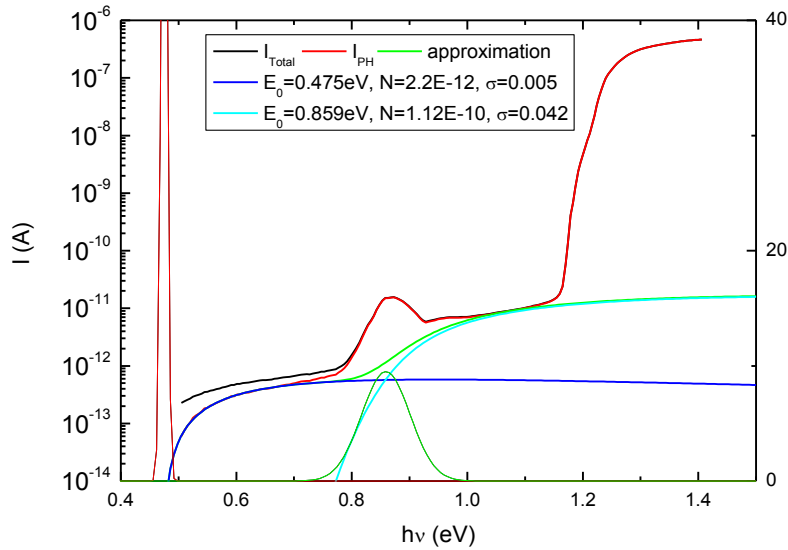


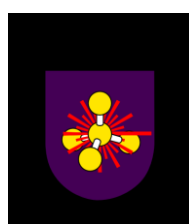
# Annealing



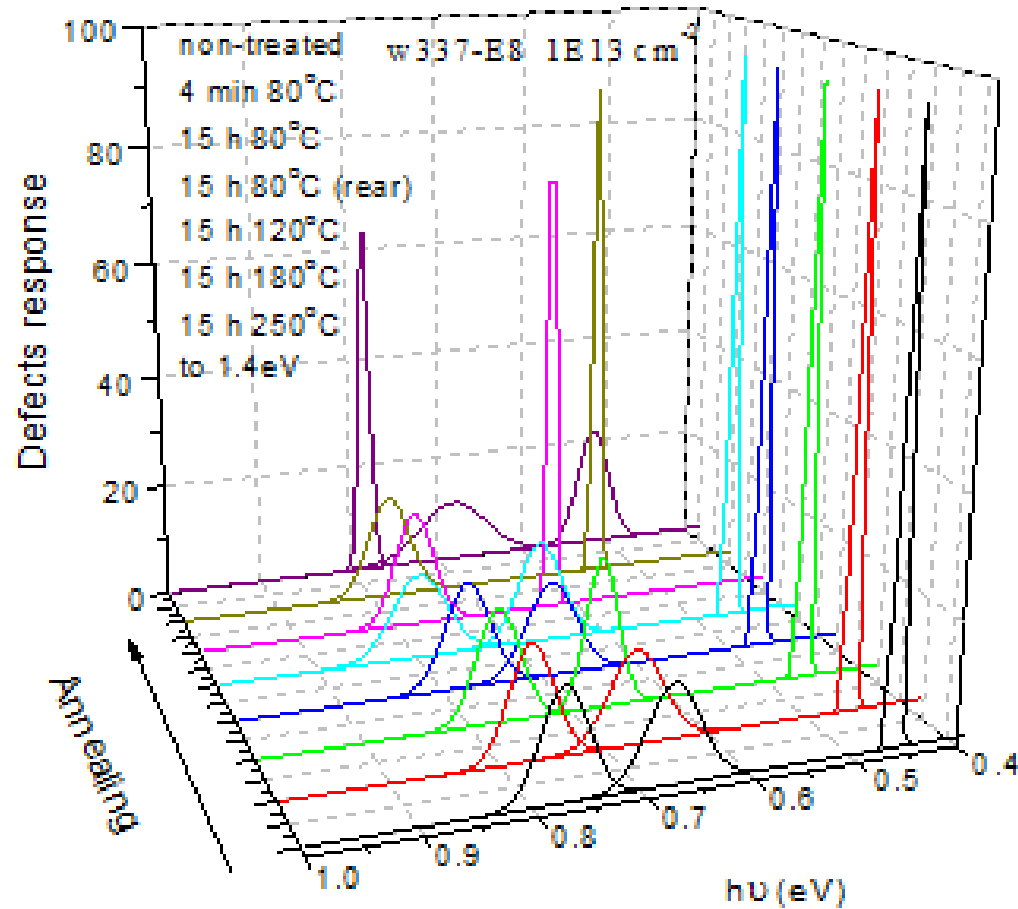


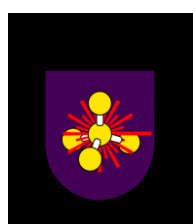
# 1e13 cm<sup>-2</sup> with a peculiarity



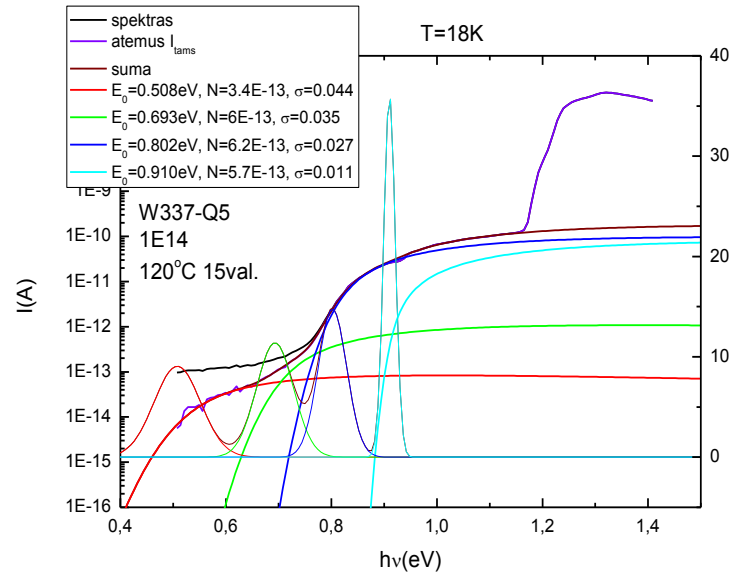
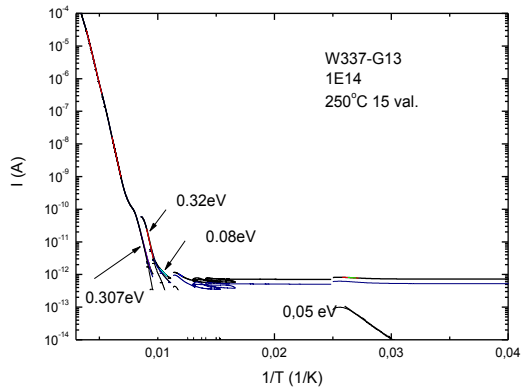
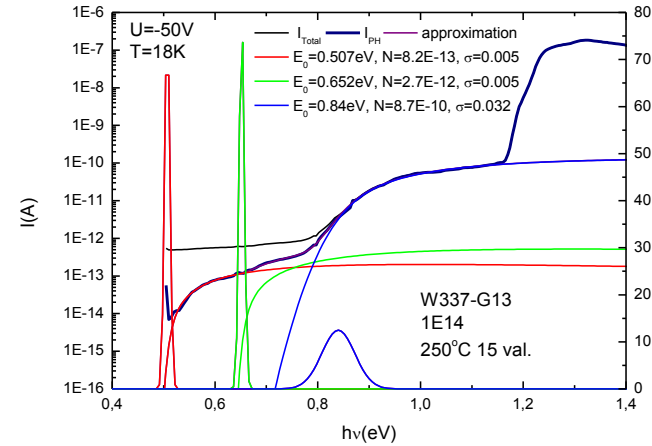
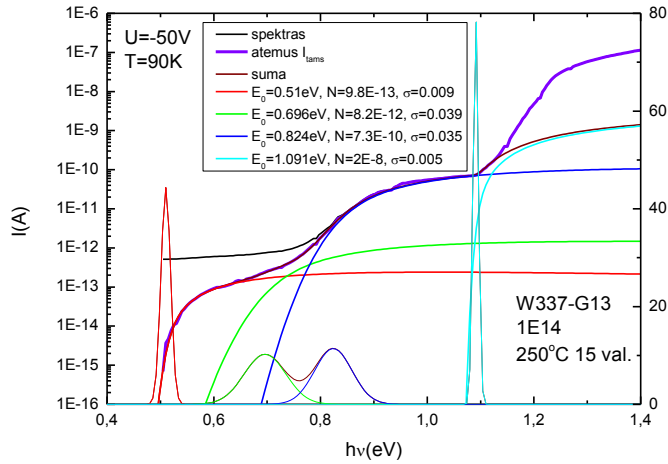


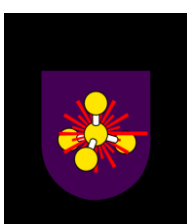
# Annealing



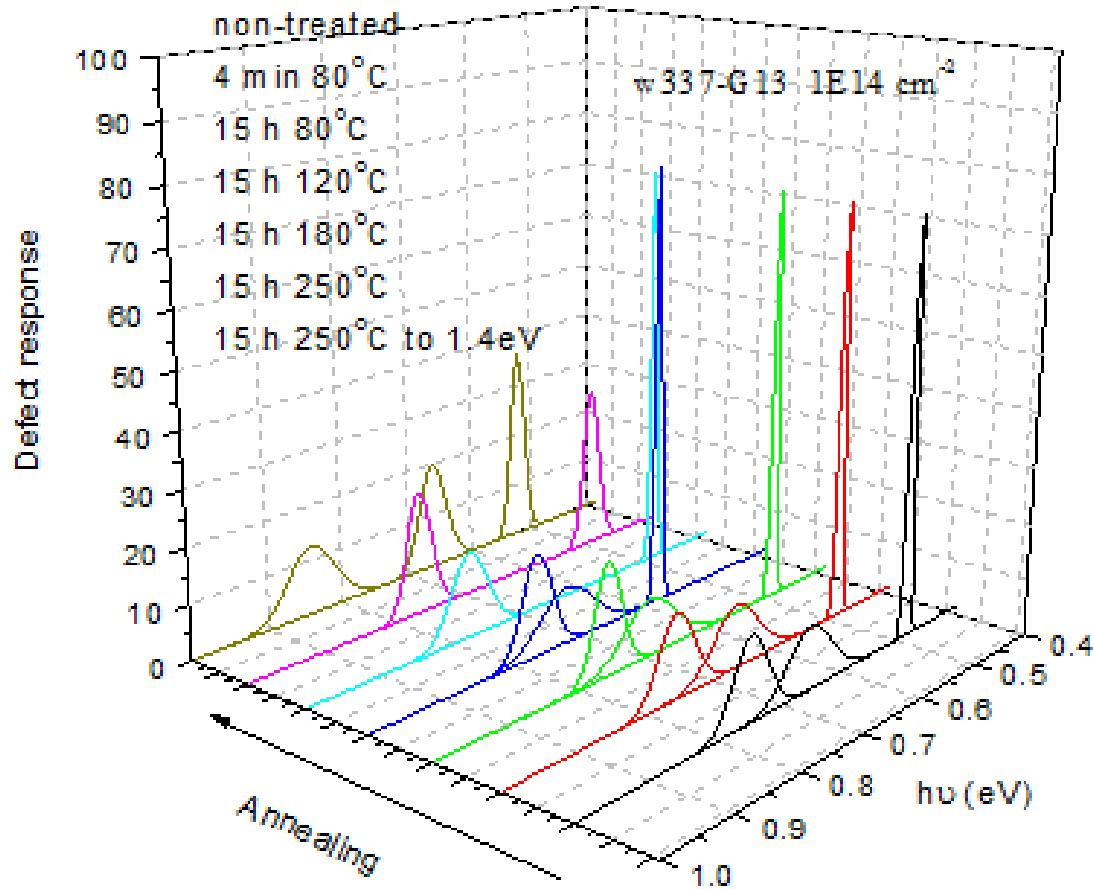


# 1e14 cm<sup>-2</sup>



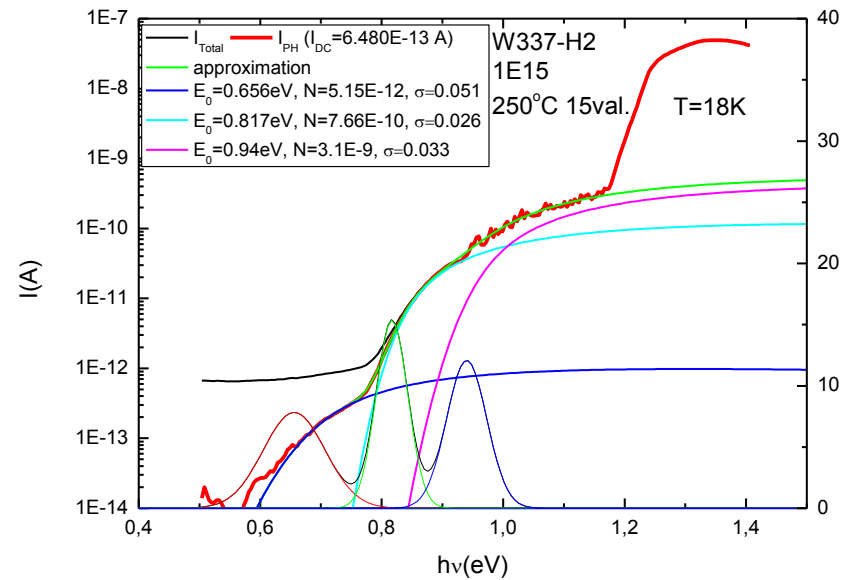
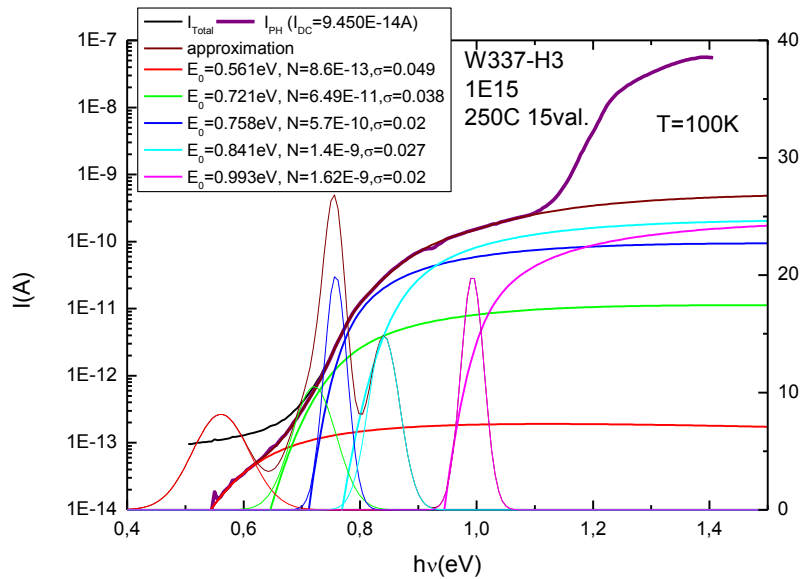
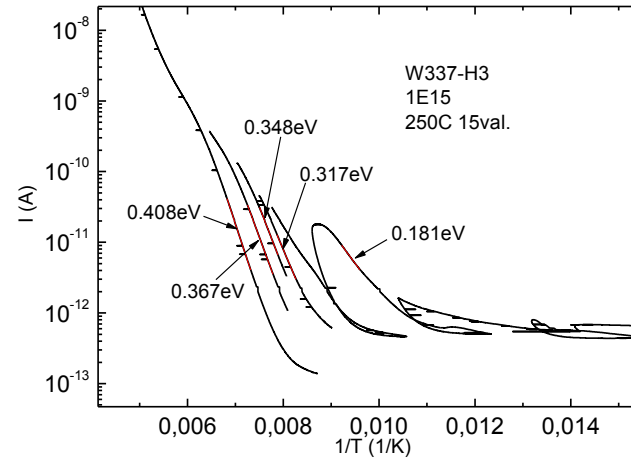
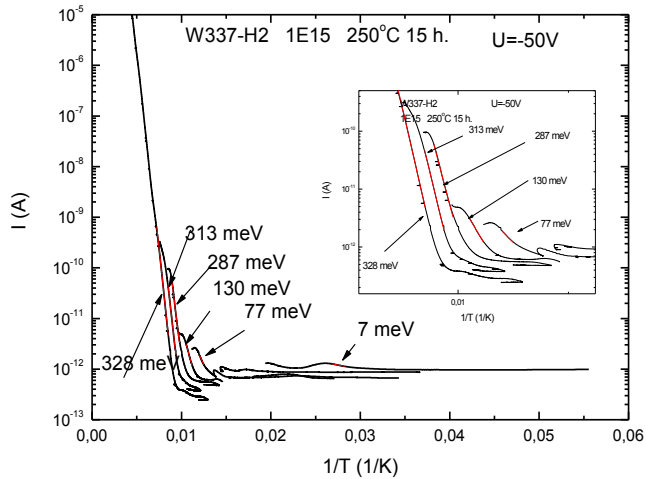


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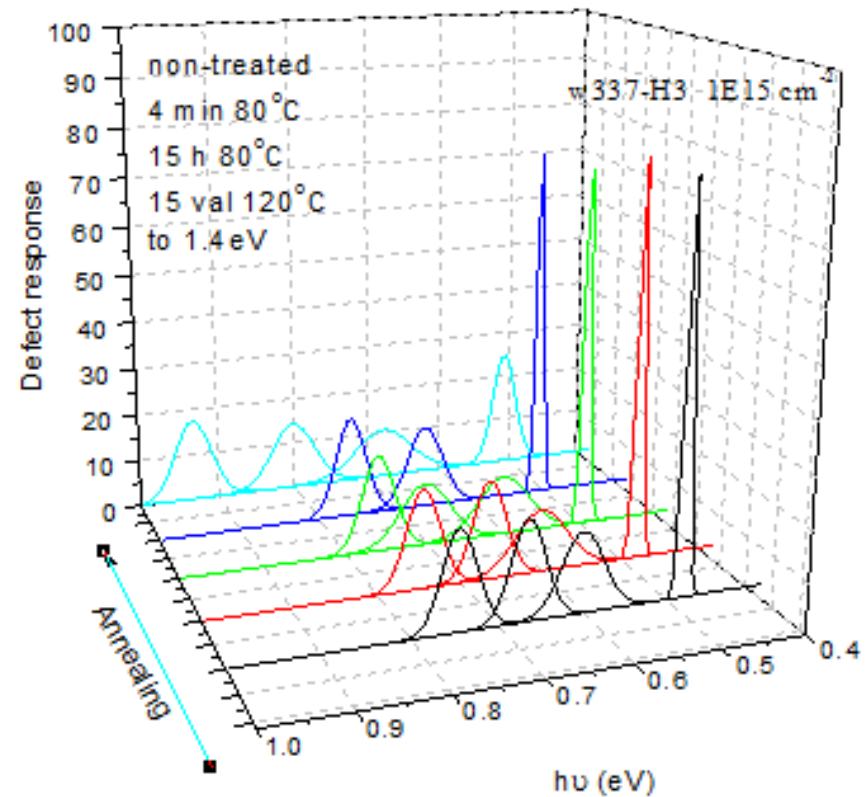
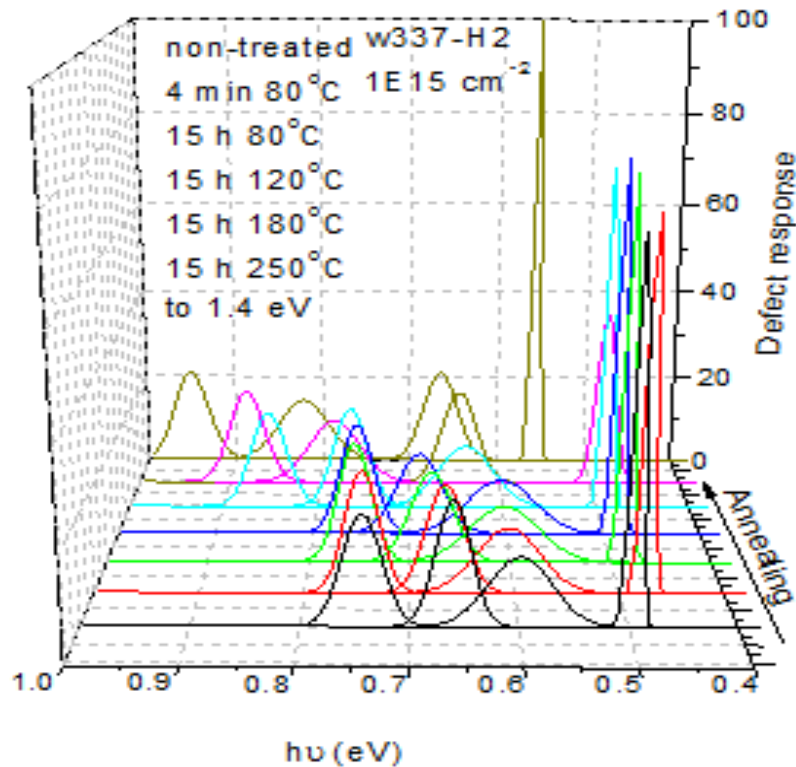


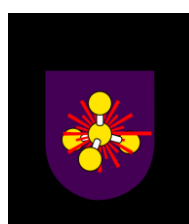


# 1e15 cm<sup>-2</sup>

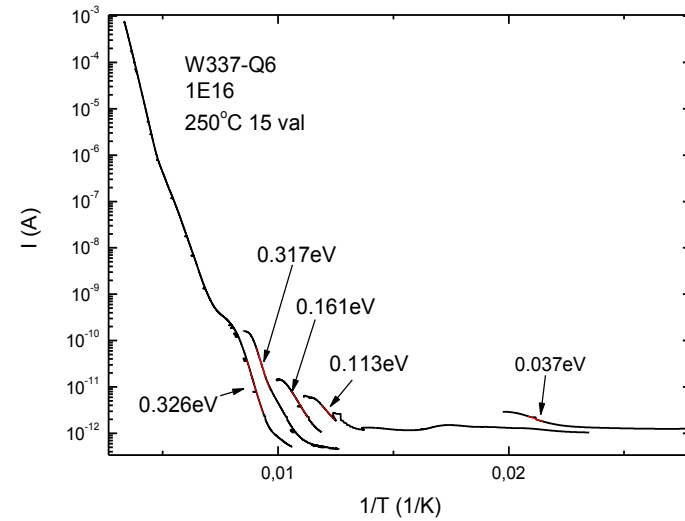
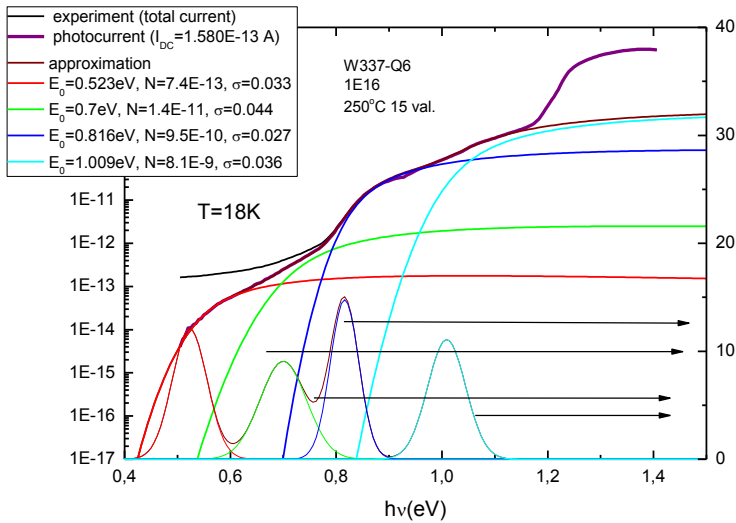


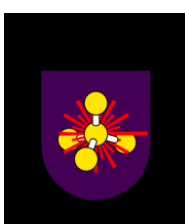
# Annealing



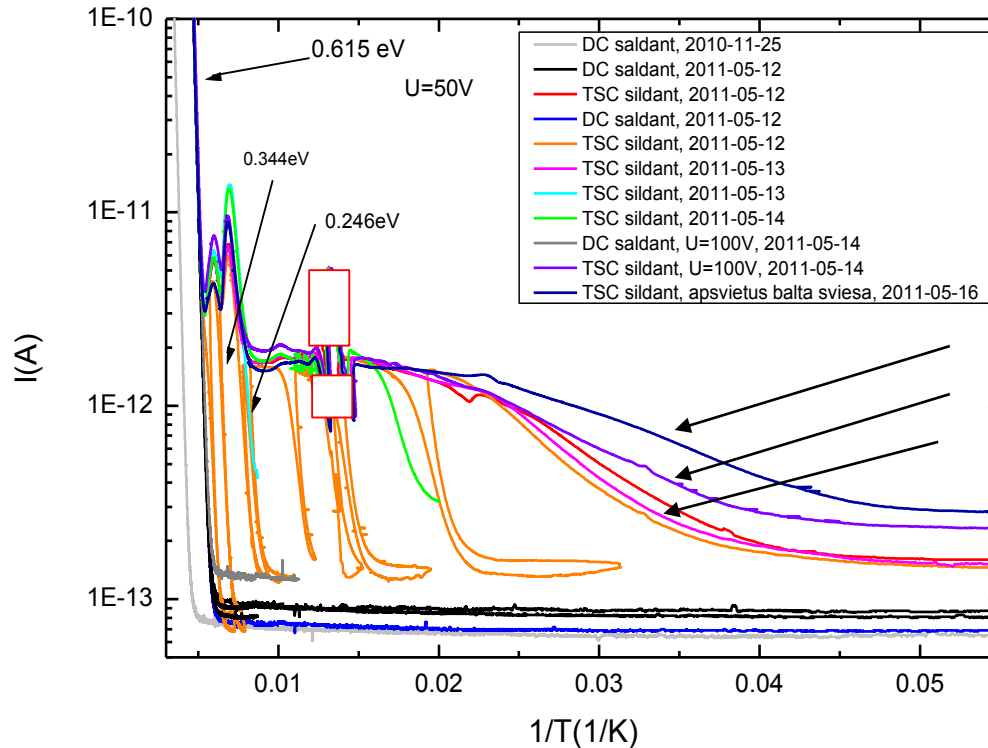


# 1e16 cm<sup>-2</sup>



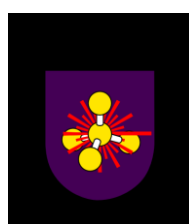


# Intriguing low activation energy values

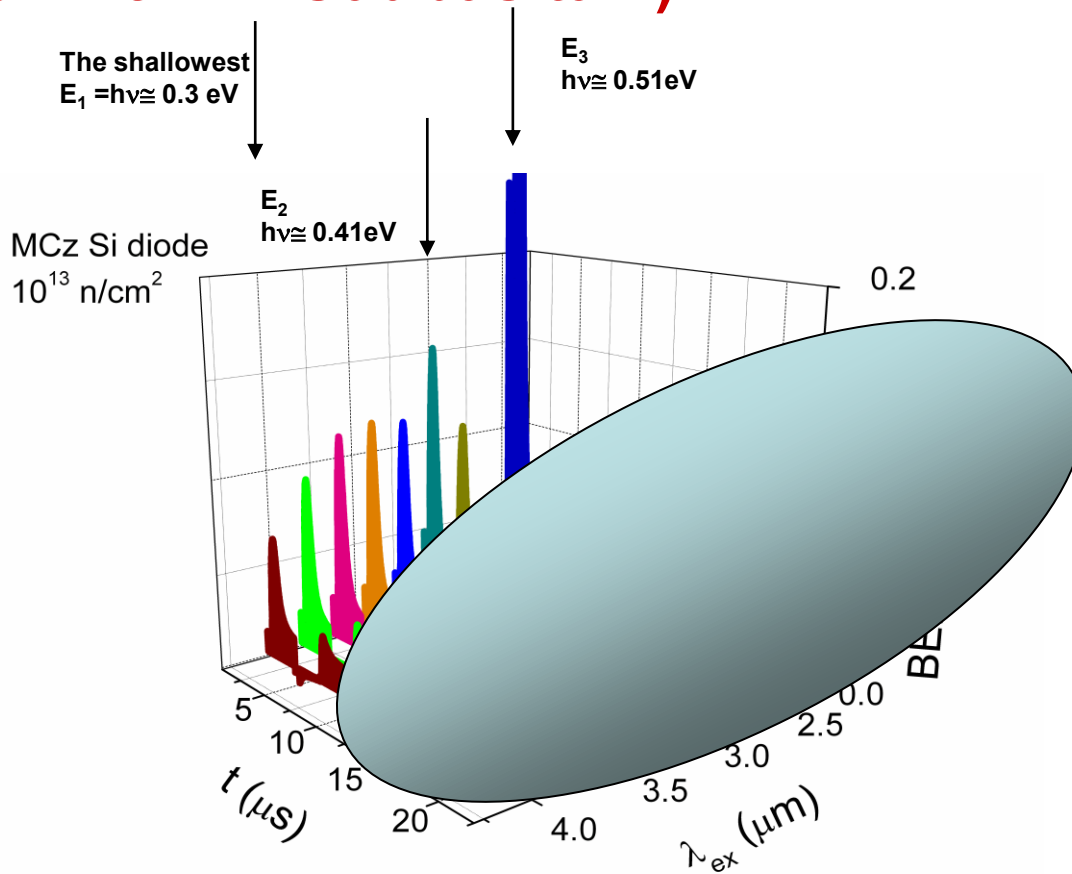


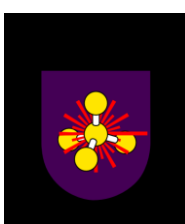
8 meV increased excitation  
9 meV 100 V bias  
15 meV 50 V bias

Dependence on the bias and on the excitation (persistent photoconductivity) showc the existence of conductivity band bottom modulation (microinhomogeneities)



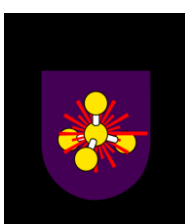
The similar photo-excitation spectra was measured at  $T=300$  K (excitation by the fs light pulse) – the deep traps are partly filled.  
 (Taken from E.Gaubas talk)





# Conclusions:

- The deep levels in the irradiated Si are distributed in 3-4 bands, and these bands are as “fingerprints”. Therefore the modeling of the device properties should take it into account (especially in analyze of the generation lifetime)
- The micro-inhomogeneities of conductivity are responsible for the small values of the TSC activation energies (and it confirms earlier reported data obtained from Hall and magnetoresistance effects investigation)
- It would be interesting to analyze all data according the WODEAN program and to fix which contribution goes from “the bulk” and from “the clusters”



THANK YOU FOR YOUR ATTENTION!

